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(12) **United States Design Patent**
Ono et al.

(10) **Patent No.:** **US D602,154 S**
(45) **Date of Patent:** **** Oct. 13, 2009**

- (54) **WHOLE FACE COVERING MASK**
 - (75) Inventors: **Kenichi Ono**, Saitama (JP); **Shuichiro Shimada**, Saitama (JP)
 - (73) Assignee: **Shigematsu Works Co., Ltd.**, Tokyo (JP)
 - (**) Term: **14 Years**
 - (21) Appl. No.: **29/294,735**
 - (22) Filed: **Jan. 24, 2008**
 - (51) **LOC (9) Cl.** **29-02**
 - (52) **U.S. Cl.** **D24/110.2**
 - (58) **Field of Classification Search** D24/110.1, D24/110.2, 110.3, 110.4; D29/108, 110; 128/205.25, 201.24, 201.25, 205.29, 206.21, 128/207.11
- See application file for complete search history.

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Primary Examiner—Ian Simmons
Assistant Examiner—Christopher Lee

(74) *Attorney, Agent, or Firm*—Flynn, Thiel, Boutell & Tanis, P.C.

(57) **CLAIM**

The ornamental design for a whole face covering mask, as shown and described.

DESCRIPTION

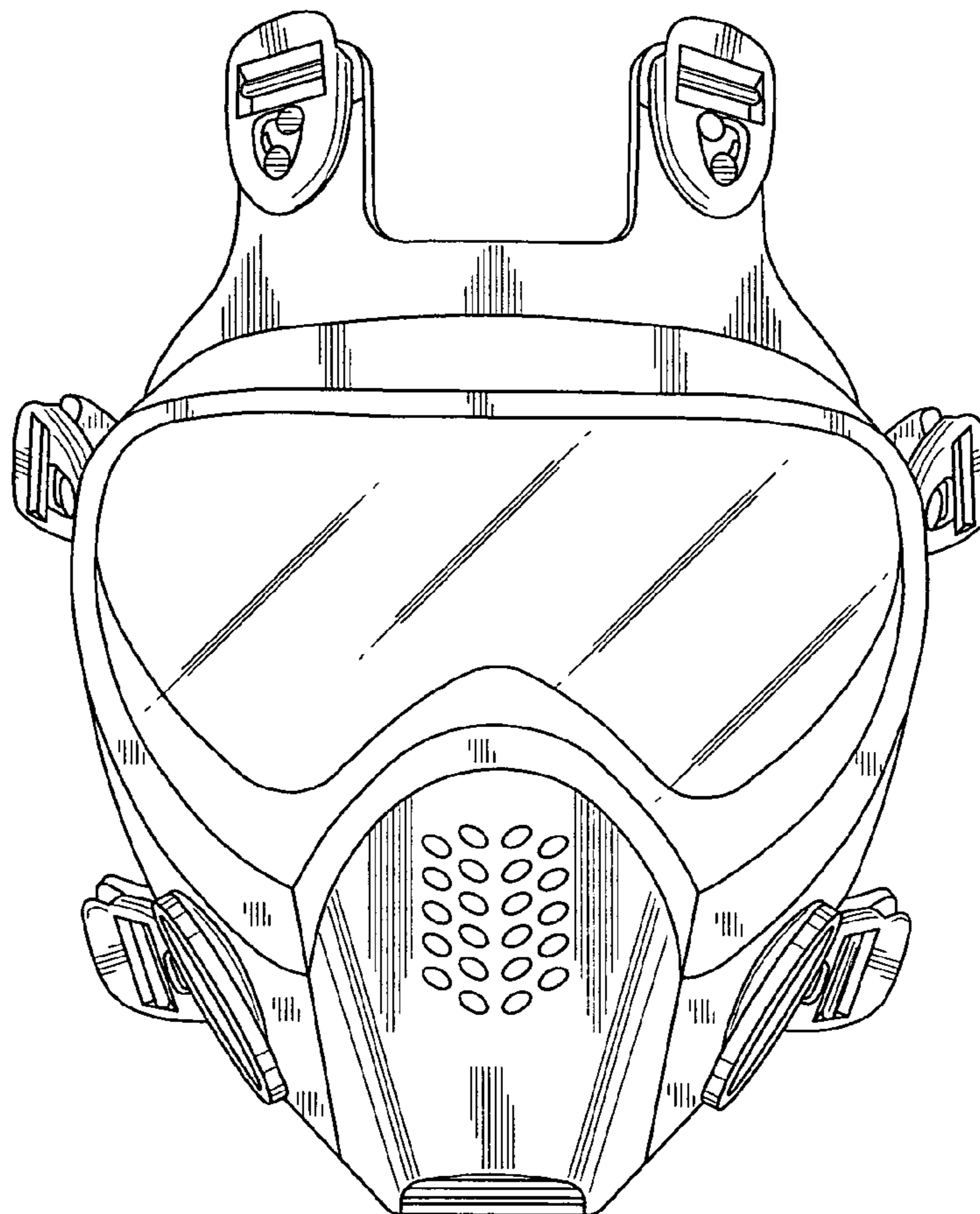
- FIG. 1 is a plan view of the whole face covering mask embodying our design;
- FIG. 2 is a front elevational view thereof;
- FIG. 3 is a rear elevational view thereof;
- FIG. 4 is a bottom plan view thereof;
- FIG. 5 is a right side elevational view thereof; and,
- FIG. 6 is a front elevational view thereof.

(56) **References Cited**

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1 Claim, 3 Drawing Sheets



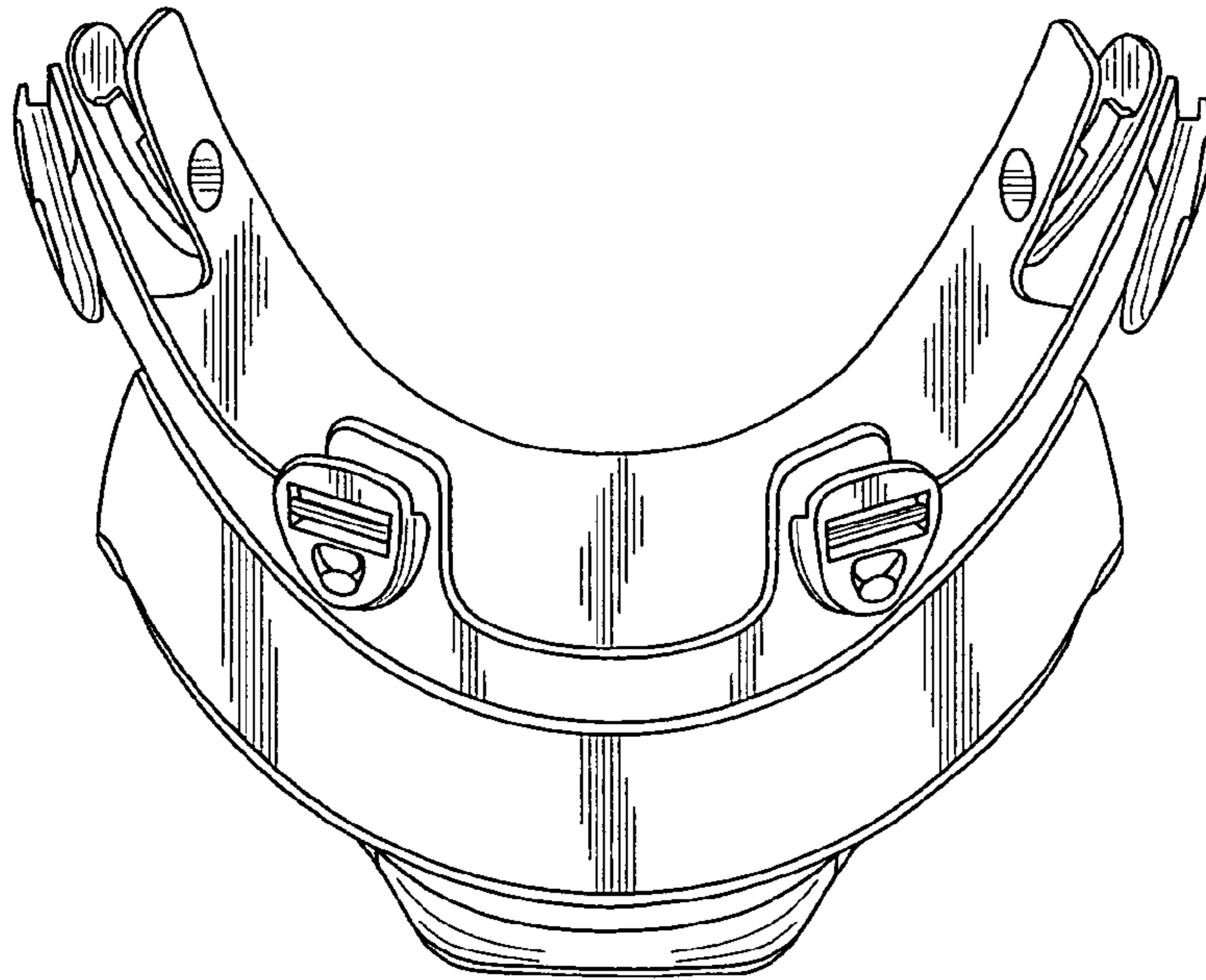


FIG. 1

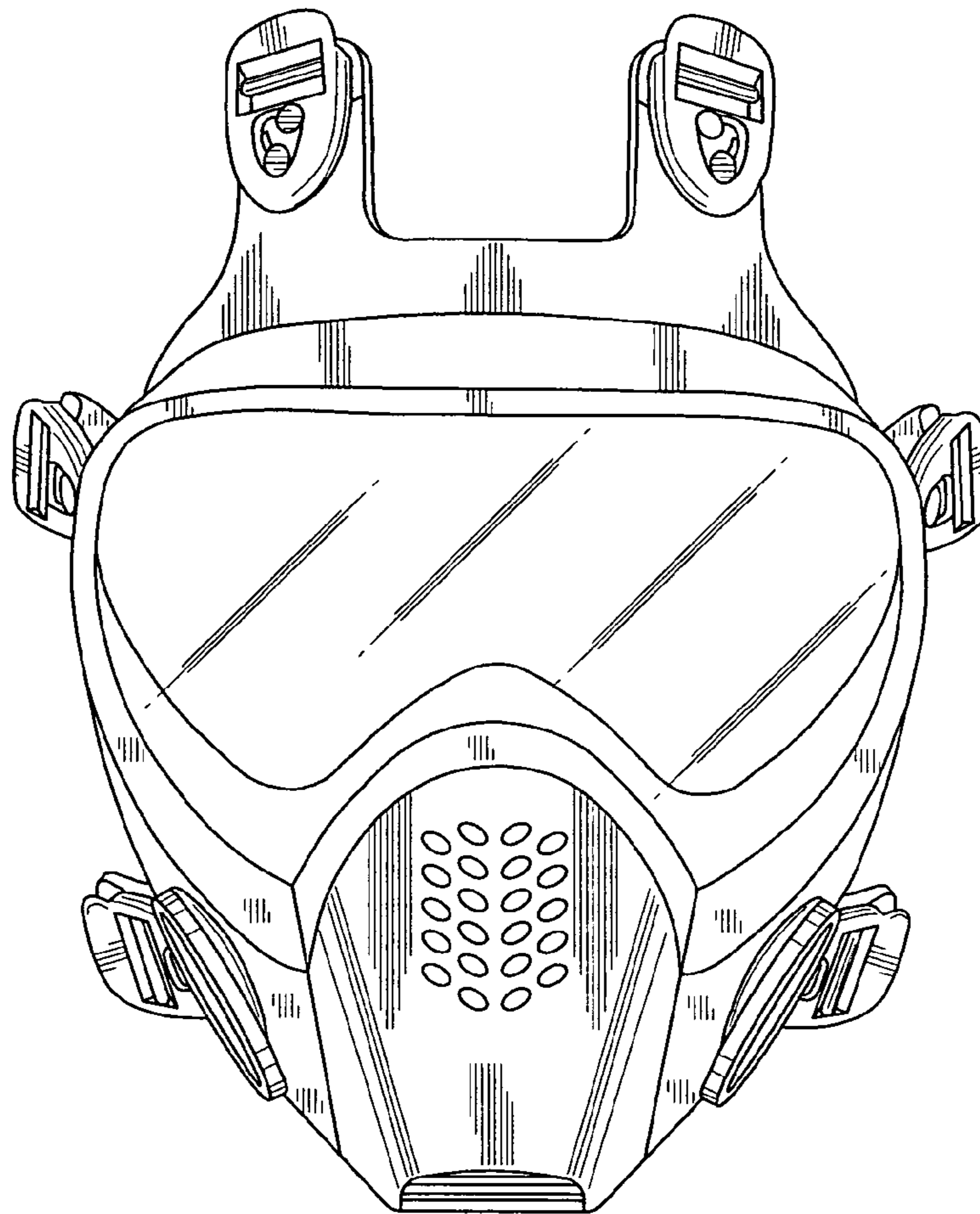


FIG. 2

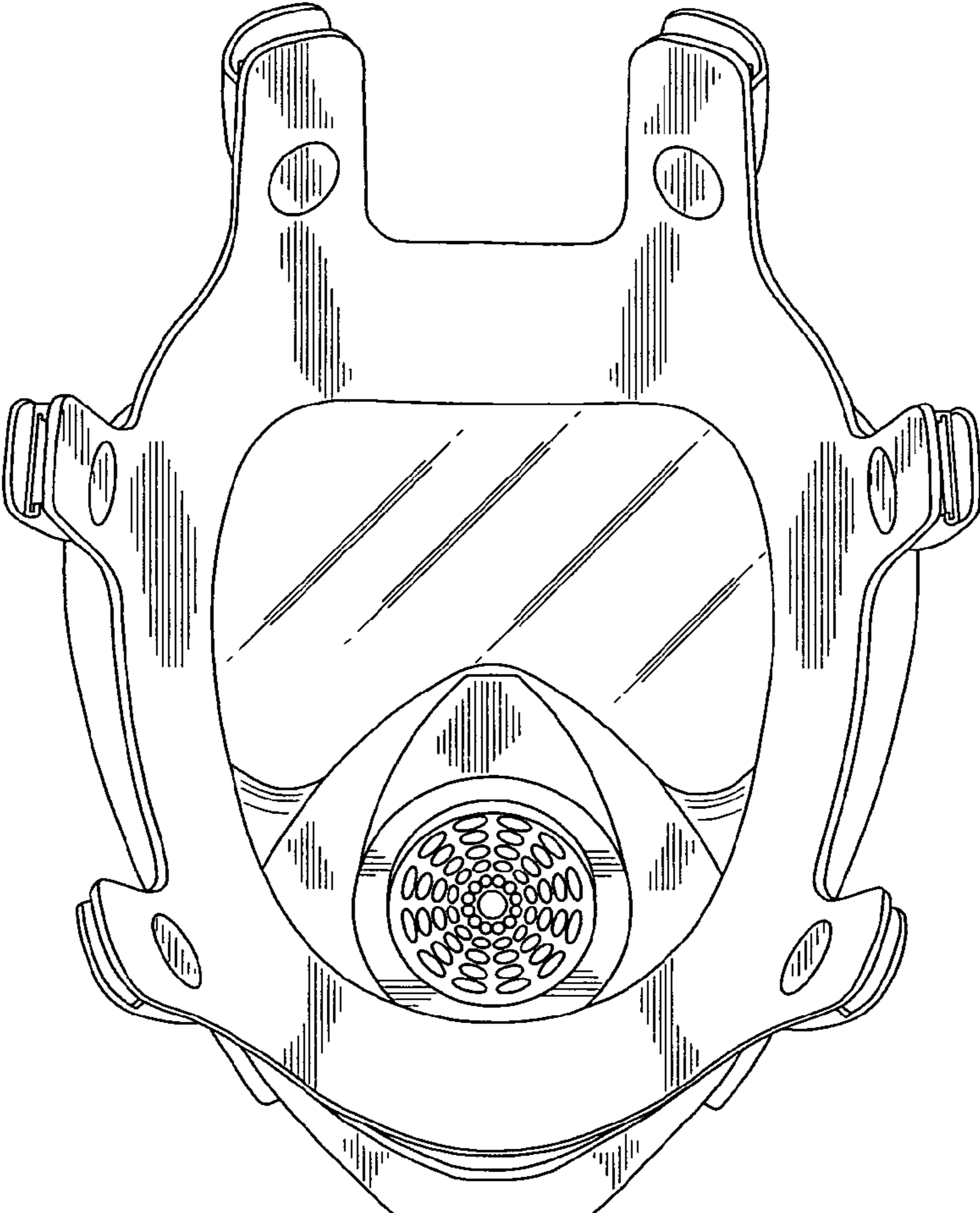


FIG. 3

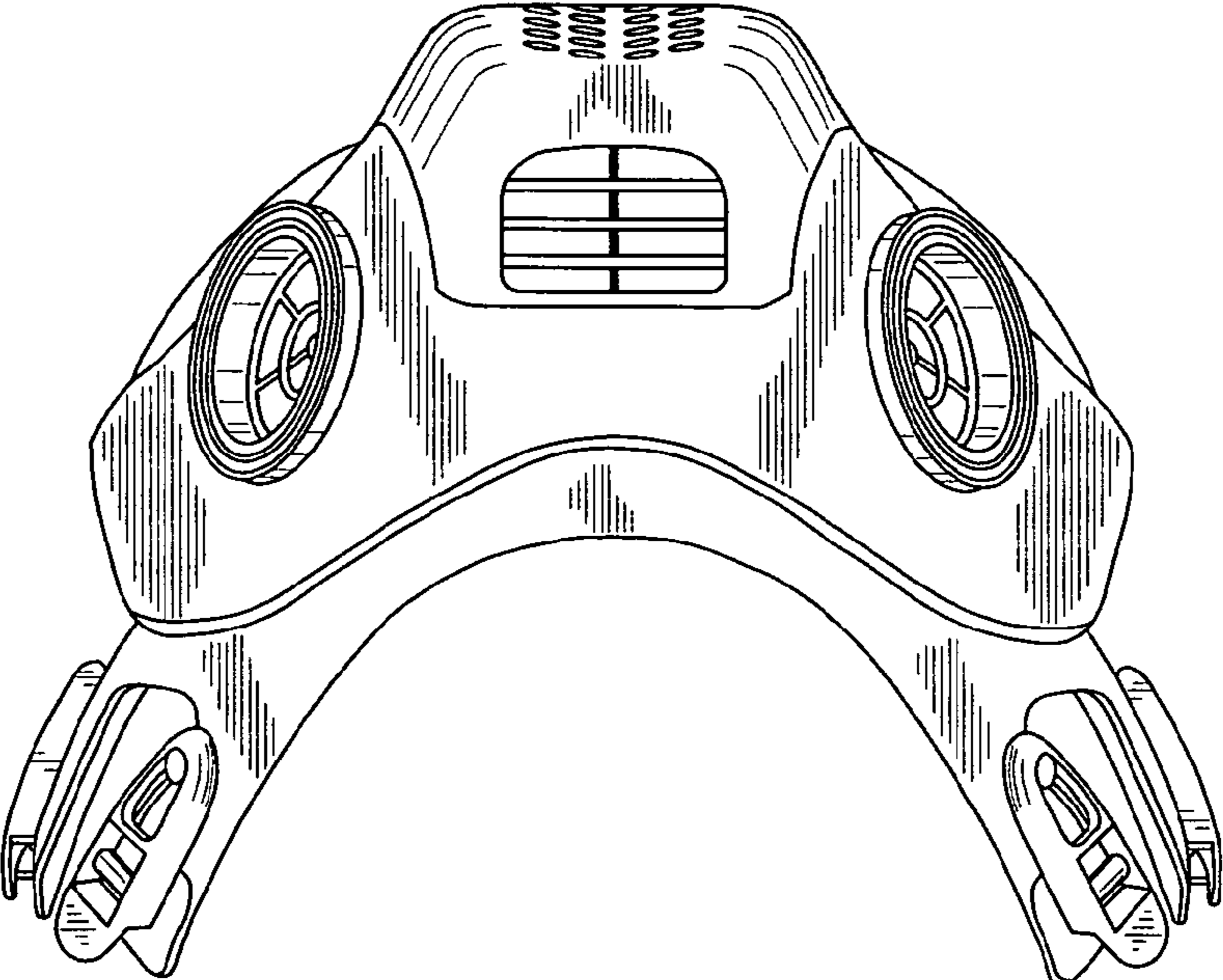


FIG. 4

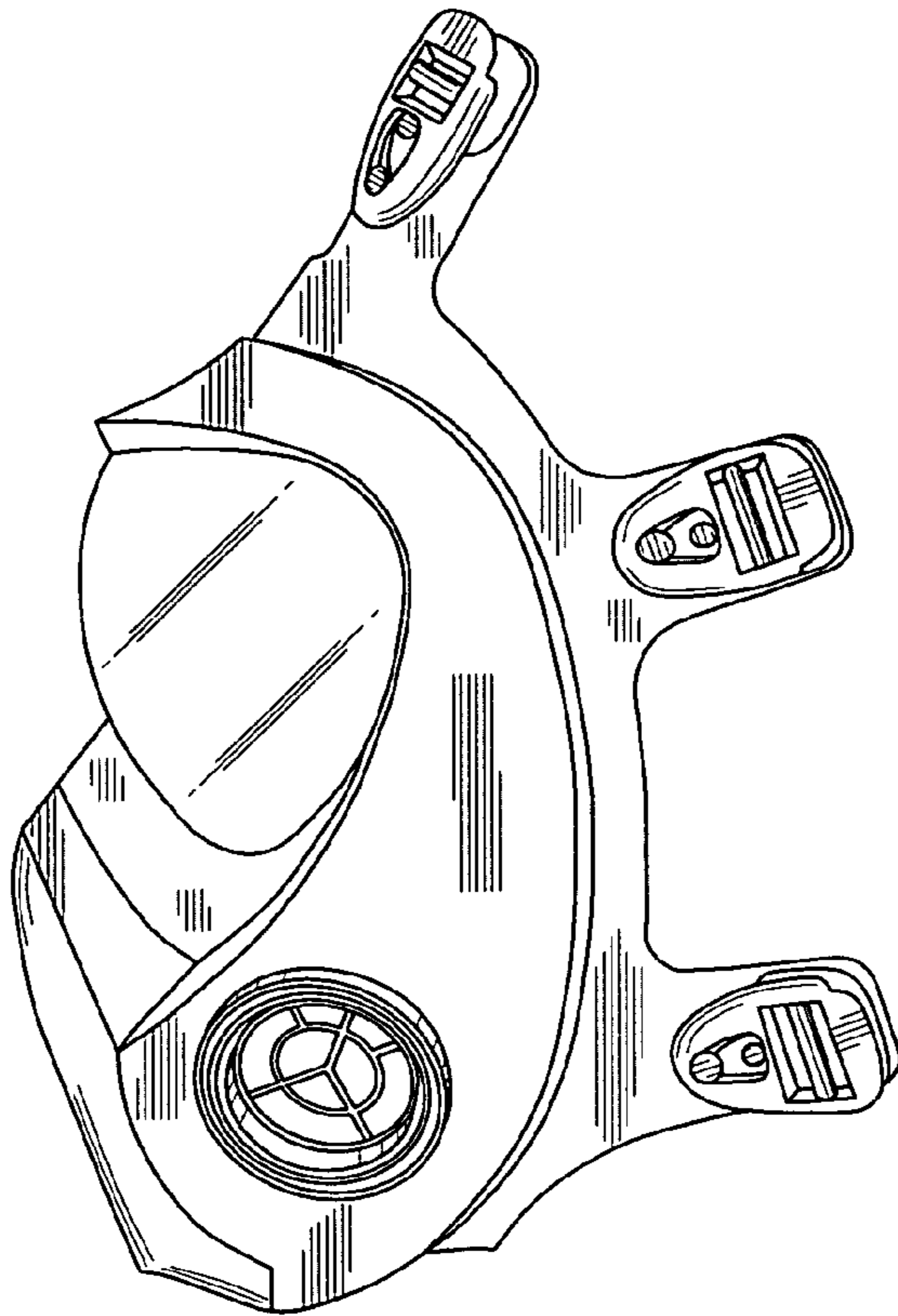


FIG. 5

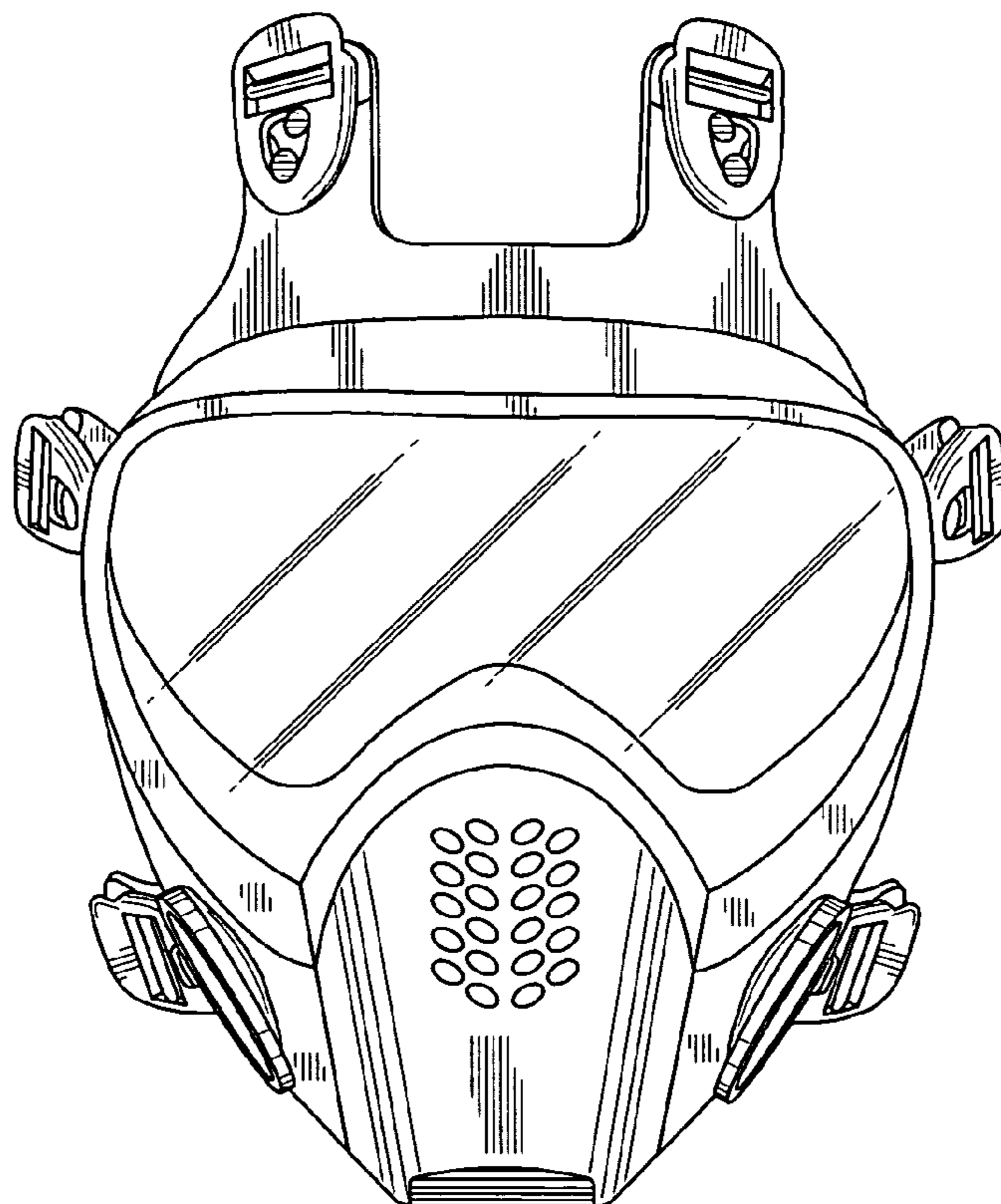


FIG. 6